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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/762,445	01/22/2004	Shenqing Fang	0180192	3707
25700	7590	10/25/2005	EXAMINER	
FARJAMI & FARJAMI LLP 26522 LA ALAMEDA AVENUE, SUITE 360 MISSION VIEJO, CA 92691			SARKAR, ASOK K	
			ART UNIT	PAPER NUMBER
			2891	

DATE MAILED: 10/25/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/762,445

Applicant(s)

FANG ET AL.

Examiner

Asok K. Sarkar

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 06 October 2005.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,2,4-9 and 11-14 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1,2,4-9 and 11-14 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 1/22/2004 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|-----------------------------------------------------------------------------------------|-----------------------------------------------------------------------------|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1 – 6 and 8 – 13 are rejected under 35 U.S.C. 102(b) as being anticipated by Hori, US 6,147,379 in view of Kobayashi, US 6,721,205.

Regarding claims 1 and 8, Hori teaches a floating gate memory cell situated on a substrate, said floating gate memory cell comprising:

- a stacked gate structure 4 and 6 situated on said substrate 1, said stacked gate structure being situated over a channel region 9 in said substrate (see Fig. 1A);
- a recess 14 formed in said substrate adjacent to said stacked gate structure, said recess having a sidewall, a bottom, and a depth (see Fig. 1A);
- a source of said floating gate memory cell 7b situated adjacent to said sidewall of said recess and under said stacked gate structure (see Fig. 1A);
- a Vss connection region 7a situated under said bottom of said recess and under said source (see Fig. 1A), said Vss connection region being connected to said source, said Vss connection region being a heavily doped region to reduce a Vss resistance (in column 9, lines 64 – 67) wherein said Vss connection region being situated under said bottom of said recess causes said source to have a reduced lateral diffusion in said channel region thereby preventing an increase in a drain

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induced barrier lowering (this feature is inherent in Hori since the Vss connection is the bit line connection of the source through which is reference voltage Vs is applied during the operation of the memory cell. Similarly, it will inherently prevent an increase in the drain induced barrier lowering) in between column 8, line 29 and column 9, line 23.

Hori shows the bit line connection in region 7a with reference to Fig. 1A, however, Kobayashi teaches that Vss connection region is the source of the memory cell through which the reference voltage is applied during the operation of the memory cell in column 19, lines 49 – 63.

Regarding claims 2 and 9, Hori teaches reduced lateral diffusion of source causing a reduction in drain induced barrier lowering in said floating gate memory cell since this feature will be inherent due to the structure of the memory cell as shown in Fig. 1A.

Regarding claims 4 and 11, Hori teaches the sidewall of the recess is substantially perpendicular to a top surface of said substrate with reference to Fig. 1A.

Regarding claims 5 and 12, Hori teaches the depth of the recess is between approximately 200.0 Angstroms and approximately 500.0 Angstroms in column 8, lines 52 – 56.

Regarding claims 6 and 13, Hori teaches ONO stack situated on the floating gate in column 14, line 14.

Claim Rejections - 35 USC § 103

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3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

6. Claims 7 and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hori, US 6,147,379 in view of Kobayashi, US 6,721,205.

Hori fails to teach the floating gate memory cell is a NOR-type floating gate flash memory cell.

Kobayashi teaches that a memory cell comprising two impurity regions isolated from each other can be adopted for NOR type memory cell array in column 4, lines 17 – 25 for the benefit of reducing the DIBL effect in column 9, lines 7 – 11.

Therefore, it would have been obvious to one with ordinary skill in the art at the time of the invention to use Hori's device in NOR type memory cell array for the benefit of reducing the DIBL effect as taught by Kobayashi in column 9, lines 7 – 11.

Response to Arguments

7. Applicant's arguments filed October 6, 2005 have been fully considered but they are not persuasive. The Applicant's main argument is with respect to the limitation that the Vss connection region is situated under the bottom of the recess and under the source (as shown in Hori's Fig. 1A), said Vss connection region being connected to said source, said Vss connection region being a heavily doped region to reduce a Vss resistance wherein said Vss connection region being situated under said bottom of said recess causes said source to have a reduced lateral diffusion in said channel region thereby preventing an increase in a drain induced barrier lowering. The Applicant argues that Hori's device because of the drain region configuration will not be able to reduce the electric field adjacent to the drain region (see 3rd paragraph of page 8). The Applicant also argues that a substantial part of Hori's Vss connection region is at the same elevation level as the source (see 2nd paragraph of page 9). These arguments are not persuasive for the reason that the Applicant's claim limitations do not specify the position level of the Vss connection region with respect to the source region. Therefore, the heavily doped Vss region of Hori will be somewhat successful in preventing the

increase in the drain induced barrier lowering throughout the overall drain region, not necessarily at the corner portion as alleged by the Applicant. Although, it is possible that Hori's device will not completely eliminate drain induced barrier lowering it will certainly lower it from the highest level developed without the presence of the heavily doped Vss region.

Conclusion

8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire **THREE MONTHS** from the mailing date of this action. In the event a first reply is filed within **TWO MONTHS** of the mailing date of this final action and the advisory action is not mailed until after the end of the **THREE-MONTH** shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than **SIX MONTHS** from the mailing date of this final action.

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Asok K. Sarkar whose telephone number is 571 272 1970. The examiner can normally be reached on Monday - Friday (8 AM- 5 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William B. Baumeister can be reached on 571 272 1722. The fax phone

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number for the organization where this application or proceeding is assigned is 571-273-8300.

10. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



Asok K. Sarkar
October 24, 2005

Primary Examiner